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	Application No.	Applicant(s)
Notice of Allowability	10/604,761	SHIH, MING-SUNG
	Examiner	Art Unit
	Stanetta D. Isaac	2812
The MAILING DATE of this communication appeal of the communication appeal claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this appropriate communication GHTS. This application is subject to	plication. If not included will be mailed in due course. THIS
1. This communication is responsive to the amendment filed of	on 10/12/04.	
2. The allowed claim(s) is/are <u>1-20</u> .		
3. The drawings filed on 14 August 2003 are accepted by the	Examiner.	
4. ☑ Acknowledgment is made of a claim for foreign priority una) ☑ All b) ☐ Some* c) ☐ None of the: 1. ☑ Certified copies of the priority documents have 2. ☐ Certified copies of the priority documents have 3. ☐ Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" on noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. ☐ A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give 6. ☐ CORRECTED DRAWINGS (as "replacement sheets") mus (a) ☐ including changes required by the Notice of Draftspers 1) ☐ hereto or 2) ☐ to Paper No./Mail Date (b) ☐ including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the depose attached Examiner's comment regarding REQUIREMENT Formatting Requirements formatting Requirements Requirement regarding REQUIREMENT Formatting Requirements formatting Requirements Requir	been received in Application Nocuments have been received in this rece	national stage application from the complying with the requirements S AMENDMENT or NOTICE OF tion is deficient. 948) attached office action of the back) of d). nust be submitted. Note the
Attachment(s)		
1. Notice of References Cited (PTO-892) Notice of Draftporson's Patent Drawing Review (RTO 048)		atent Application (PTO-152)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summary Paper No./Mail Date	e
 Information Disclosure Statements (PTO-1449 or PTO/SB/08 Paper No./Mail Date 	8), 7. Examiner's Amendr	
4. Examiner's Comment Regarding Requirement for Deposit		nt of Reasons for Allowance
of Biological Material	9.	

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REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance:

The closest prior art of record, the combination Fukata et al., US Patent 6,452,241 and Somekh et al., US Patent 4,231,811, fails to show, performing an ion implantation step using the patterned photoresist layer as a mask for simultaneously forming a source/drain in the first region of the polysilicon layer and an lightly doped (LDD) in the polysilicon layer underneath the edge portion of the patterned photoresist layer.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Stanetta D. Isaac whose telephone number is 571-272-1671. The examiner can normally be reached on Monday-Friday 9:30am -6:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Niebling can be reached on 571-272-1679. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Stanetta Isaac Patent Examiner December 3, 2004

John F. Niebling

Supervisory Patent Examiner Technology Center 2800